

Sir:

PATENT APPLICATION

In re Application of: Examiner: M. Landau Yoshiyuki NAGAI et al. Group Art Unit: 2815 Application No.: 09/839,139 Confirmation No.: 1616 Filed: April 23, 2001 For: LASER OSCILLATION APPARATUS, EXPOSURE October 21, 2003 APPARATUS, SEMICONDUCTOR DEVICE MANUFACTURING METHOD, SEMICONDUCTOR) MANUFACTURING FACTORY, AND EXPOSURE APPARATUS MAINTENANCE METHOD TECHNOLOGY CENTER 2800 Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 PRELIMINARY AMENDMENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Prior to further examination on the merits, please amend the above-identified application as follows: